

microCELL™ TLS

On-the-Fly Cell Cutting System using Thermal Laser Separation

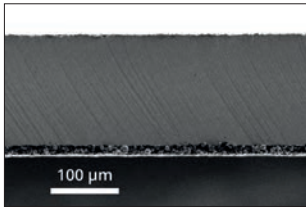
3D-Micromac's microCELL™ TLS is a highly productive laser system for separation of standard silicon solar cells into half cells. The microCELL™ TLS meets cell manufacturers' demands by retaining the mechanical strength of the cut cells. The ablation free process guarantees an outstanding edge quality. Laser processing on-the-fly and an innovative handling concept enable maximum throughput and yield in the full-scale manufacturing of crystalline half cells.

microCELL™ TLS offers:

- On-the-fly laser processing with unbeatable cost-benefit ratio
- One-pass contactless dicing process
- High throughput > 5,000 wph on single lane
- Dicing speed > 300 mm/sec
- Low cost of ownership and CAPEX
- Inline integration into existing production lines or stand alone



microCELL™ TLS - System Configuration



TLS cleaving edge of a polycrystalline solar cell

Configuration packages

Stand-alone

- Two working areas on single lane for initial scribing and TLS cleaving
- Handler-tool-in for full cells and handler-tool-out for half cells

Inline

- Two working areas on single lane for initial scribing and TLS cleaving
- Inline system for complete integration into existing production lines

Options

- Breakage control / NIO discharge
- RFID reader
- Data matrix reader (DMC)
- Wafer buffer system
- MES system
- Loading- and unloading handling as on customer specification

Wafer size	<ul style="list-style-type: none"> • 156 x 156 mm² up to 165 x 165 mm² • Other sizes on request, square and pseudo-square shapes possible
Throughput	<ul style="list-style-type: none"> • > 10,000 half cells on single lane > 300 mm/s
Cleavage pattern	<ul style="list-style-type: none"> • Half cells • Quarter cells • Other pattern on request
Laser sources	<ul style="list-style-type: none"> • Two integrated long lifetime, low maintenance fiber laser sources
Laser processing	<ul style="list-style-type: none"> • On-the-fly
Beam delivery unit	<ul style="list-style-type: none"> • Beam delivery unit including two processing heads for initial scribing and TLS cleaving
Active alignment	<ul style="list-style-type: none"> • Wafer alignment via sensor system
Handling/positioning system	<ul style="list-style-type: none"> • Continuously running transport belt
Loading/unloading	<ul style="list-style-type: none"> • Automatic loading and unloading of wafer via cassette/magazine system • Inline integration possible
Dimensions	<ul style="list-style-type: none"> • Approx. 2,150 x 1,250 x 2,312 mm³ (L x W x H)
Standards	<ul style="list-style-type: none"> • Laser safety class 1 • CE compliant

Changes in accordance to technical progress are reserved.